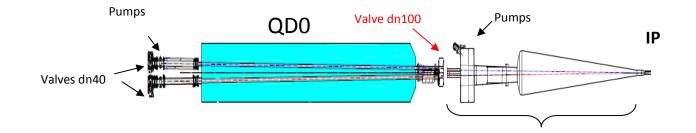
# IP vacuum

### possible changes towards L\*=4m



Need a pumping system between the two DN 100 valves (hot part of the IP chamber)

Proposal for a distributed pumping: coating NEG (Non evaporate Getter)

Length reduction

Improved vacuum level (to quantify)

Need to in situ baking of beam pipe

### IP vacuum

#### Dynamic pressure

Gas desorption needs to be studied for the IP vacuum consideration.

Photon , ion and electron desorption E-cloud Lost electron positron

# working proposals

Simulation with distributed pumps NEG under static pressure (without lumped pump)

Informations about particles flow striking the surface per unit length

Geometry QDO chamber ? Magnet feature, beam size, Beam screen, sticking coefficient, ....